



PATENT

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Sang Young Kim et al. Examiner: Unknown
 Serial # : Unknown Group Art Unit: Unknown
 Filed : Same date herewith Docket: 9983.3US01
 Title : METHOD FOR FILLING CONTACT HOLES WITH METAL BY
 TWO-STEP DEPOSITION

PRELIMINARY AMENDMENT

Hon. Commissioner of Patents
 and Trademarks
BOX PATENT APPLICATION
 Washington, D.C. 20231

Dear Sir:

Kindly amend the above-identified patent application as follows:

IN THE CLAIMS

On page 8, at line 2 of Claim 1, kindly delete "layer" and insert therefor 1 layers, said method comprising the steps of-- *a'*

On page 8, at the last line of Claim 1, kindly replace the semi-colon ";" with a period ---.

REMARKS

Claim 1 is amended to now include a recommended transitional phrase and to correct a typographical error.

Applicant respectfully requests that the preliminary amendment described herein be entered into the record prior to examination and consideration of the above-identified application. Examination and consideration of the application as amended is respectfully requested.

If a telephone conference would be helpful in resolving any